

Refine Search

Search Results -

Terms	Documents
L1 and ((remov\$ or etch\$) near5 (oxide near4 oxynitride)).clm.	14

Database:

US Pre-Grant Publication Full-Text Database
 US Patents Full-Text Database
 US OCR Full-Text Database
 EPO Abstracts Database
 JPO Abstracts Database
 Derwent World Patents Index
 IBM Technical Disclosure Bulletins

Search:

L6

Refine Search

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Search History

DATE: Sunday, October 23, 2005 [Printable Copy](#) [Create Case](#)

Set Name Query
 side by side

Hit Count Set Name
 result set

DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L6 L1 and ((remov\$ or etch\$) near5 (oxide near4 oxynitride)).clm. 14 L6

L5 L4 25 L5

DB=USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L4 L3 25 L4

DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

L3 L2 and (form\$ near4 oxide) 36 L3

L2 L1 and ((remov\$ or etch\$) near5 (oxide near4 oxynitride)) 74 L2

L1 (ammonia or "NH.sub.3") same oxynitride same oxide 1671 L1

END OF SEARCH HISTORY